



TopSpec - 829157

WP6 - Modification of the Orbitrap mass spectrometer

Deliverable: D6.1 - Modified Orbitrap Q Exactive HF X installed

Task: In parallel to Task 6.1 (Installation of a loaned Q Exactive instrument to Fasmatech to support Omnitrap development), a standard Orbitrap Q Exactive HF-X (or a similar high-end instrument) will be modified to improve its performance for desolvation and transmission of intact antibodies. Based on research using Q Exactive UHMR and standard HF-X instruments, there is clearly a reserve for optimizing the desolvation region of the atmosphere-to-vacuum interface that deserves a more detailed exploration. In parallel to this, a joint work with Spectroswiss and Fasmatech will be started on integration of instrument control software using application programming interface (API) to be provided by TF. This work includes also development of tuning and calibration procedures specific for antibody analysis in order to ensure best top-down performance, integration of data for all fragmentation methods and cross-section measurements. After testing of all functional units, the resulting will be delivered and installed at KI and performance protocol will be completed for a test set of compounds.

Content:

Authors: Alexander Makarov and Kyle Fort, Thermo Fisher Deadline: 11/30/2022



1. Description of action

Part 1. Initial assembly and testing of the final instrument.

Successful installation of a new Orbitrap Exploris 480 instrument in Fasmatech lab and its coupling to Omnitrap back-end was described in the Month 30 WP6 report and is illustrated in Appendix 1. This document contains also illustration of the modified time sequence of Orbitrap Exploris 480 MS needed for such integration.

In addition to and beyond the initial scope of this work package, multi-platform integration of Omnitrap with the older Exactive family of instrument was implemented for the most popular Q Exactive Plus and HF instruments. In process, unexpected residual ions were discovered to leak through the closed ion gate of Exactive instruments and additional research allowed to resolve this issue (**Appendix 1**).

Following this, an Q Exactive HF/Omnitrap instrument was successfully installed at Institute Pasteur partner as a part of WP1.

The extensive process of integrating Omnitrap and Exploris required development of two-way communication utilizing application-programming interface (API). **Appendix 2** contains more detail on this important software tool. On Orbitrap Exploris instruments, access to API is obtained via a click-through license agreement.

Part 2. Installation and testing of the final instrument at partner KI.

Successful installation of the complete Orbitrap Exploris 480/Omnitrap/IMS instrument in Karolinska institute is covered by Installation Protocol of **Appendix 3**. This report contains also description of user interface and methods of operations of the system.



6. Performance

Deliverable D6.2 was completed as detailed in Appendices 1-3.

Appendix 1

WP6: Modification of the Orbitrap Mass Spectrometer

Appendix 1. Initial installation of Orbitrap[™] Exploris[™] instrument

Kyle Fort, Alexander Makarov 22-07-21

The world leader in serving science

Orbitrap Exploris 480 Mass Spectrometer

Ultra-High Field Orbitrap Mass Analyzer





- Exploris 480 Mass Spectrometer was delivered to Fasmatech and was installed on December 14-18th, 2020
- Instrument offers increased robustness, higher resolution, and easier access for hardware modification
- The Exploris is compatible with Field Asymmetric-waveform Ion Mobility, enabling additional specificity

Orbitrap Exploris 480 Mass Spectrometer: Modification with the Omnitrap



3

Appendix 1

Thermo Fisher



- Combination of the Omnitrap with the Exploris 480 MS will occur by installing the Omntrap on the back of the Ion Routing Multipole (IRM, formally termed HCD-cell)
- Ions will be transported from the IRM to the Omnitrap for fragmentation and the returned to the Exploris for mass analysis
- Customized hardware developed in collaboration between Thermo Fisher and Fasmatech to enable mechanical attachment
- Customized MS instrument control software to enable ion transport to and from the Omnitrap

Omnitrap Installed on Exploris 480 MS



Appendix 1

Thermo Fisher



Side View

4

Customized Instrument Control Software: External Instrument Mode

Appendix 1

Modified Operation of Ion Optics



Customized Voltage and Timing Control

cell Exit Lens



User Interface Built-in to Instrument Control Software



HCD External Instrument Mode	
External Instrument Mode *	On
Offset to External Instrument * (V)	50
Gradient to External Instrument * (V)	-30
Transfer Time to External Instrument * (ms)	15
Offset from External Instrument * (V)	-50
Gradient from External Instrument * (V)	30
Transfer Time from External Instrument * (ms)	10
C-Trap Exit Lens Close * (V)	35
HCD Exit Lens Mode	Lens
HCD Exit Lens to External Instrument * (V)	5
HCD Exit Lens from External Instrument * (V)	-5
Trigger Voltage High * (V)	5
Trigger Voltage Low * (V)	0

Exploris 480/Omnitrap Combination: Initial Data

Appendix 1



- After modification and software implementation, initial data was collected using the MS calibration solution, Flexmix
- The hardware addition of the Omnitrap showed no noticeable effect on the operation of the MS
- When the External Instrument Mode is enabled, but ions are not transported to the Omnitrap, >80% ion transmission is preserved
- Upon transmitting ions to the Omnitrap with the External Instrument Mode, transmission efficiency is ~90%

Beyond WP6: Multiplatform Integration









- The Omnitrap was enabled on two other Orbitrap Mass Spectrometer platforms prior to the coupling to the Exploris 480: Q Exactive Plus and Q Exactive HF MS
- These mass spectrometers acted as a test bed for optimizing operation of the Omnitrap operation and initial data collection
- Transfer of instrument development to the new Orbitrap Exploris platform improves analytical performance of the complete instrument and long-term commercial prospects for Omnitrap but required significant additional work on all aspects of integration



Appendix 1

Thermo Fi

- Initial experiments on Exactive-based Mass Spectrometers, modified with the Omnitrap, showed that very small
 amounts of the precursor remained even after "elimination" in the Omnitrap
- These residual precursor ions overlapped with higher m/z ions from the MS³/MS⁴ experiments, limiting sequence coverage
- In-depth troubleshooting and root-cause-analysis was needed in order to determine the source and find a solution to eliminate these ions



 The ion optics were modified to install the Omnitrap at the end of the HCD-cell

Appendix 1

Thermo Fishei

- Where are the Residual Precursor ions coming from? Multiple possibilities:
 - Ions being trapped in the HCD Cell
 - Ions being trapped in the C-Trap
- Issue was difficult to replicate off-site and nonreproducible, adding to complexity



- Causes, Multiple possibilities:
 - Ions being trapped in the HCD Cell
 - Ions being trapped in the C-Trap
- Potential Solutions:
 - Turning off HCD Cell RF when ions were in Omnitrap

Appendix 1

ThermoFis

- Turning off C-trap RF when ions were in the Omitrap
- Both
- Custom software was written for each iteration of potential solution; while each step showed improvement, neither nor both fully solved the issue



- Causes, Multiple possibilities:
 - Ions being trapped in the HCD Cell
 - lons being trapped in the C-Trap
 - Ions leaking from Quadrupole in spite of gating

Appendix 1

Thermo Fishei

- Potential Solutions:
 - Turning off HCD Cell RF when ions were in Omnitrap
 - Turning off C-trap RF when ions were in the Omitrap
 - Applying a high resolving DC potential to Quadrupole during "ion blocking", i.e. when split gate was closed



With both RF solutions and the high resolving DC solution

Appendix 1

Thermo Fisher



Appendix 2

WP6: Modification of the Orbitrap Mass Spectrometer

Appendix 2. Application Programming Interface for Orbitrap[™] Exploris[™] instrument

The world leader in serving science

Exploris 480/Omnitrap Combination: Developing High-Throughput Workflow via the API

Appendix 2

Thermo Fisher



- For a standalone MS, DDA and targeted workflows are available; however, these are not directly compatible with the Omnitrap addition as there is no communication between the two instruments
- The API (Application Programming Interface) allows
 two-way communication
- Via the API, Fasmatech is able to get spectral information and send custom scans to the mass spectrometer, allowing high-throughput, e.g. DDA and targeted, workflows

Exploris 480/Omnitrap Combination: Details

•

Appendix 2





- API allows to automate essentially any operation available in Tune View of Exploris or Q Exactive MS
- API examples for the Exploris: https://github.com/thermofisherlsms/iapi/tree/master/examples /Exploris

Figures from: ASMS Poster, "Customized Real-Time Control of Benchtop Orbitrap MS" by Kuehn et al.

Example of API usage for Omnitrap operation



Appendix 3



WP6: Modification of the Orbitrap Mass Spectrometer

Appendix 3. Installation test protocol of Omnitrap[™] – Exploris[™] 480 instrument





The Omnitrap / Exploris 480 system

Omnitrap/IMS installed on an Exploris 480 MS at Fasmatech's DemoLab, Athens, Greece.







The Omnitrap / Exploris 480 system

ECH

Omnitrap/IMS/Exploris 480 system installed at Karolinska Institute, Stockholm (October 2022)
 Appendix 3



The Omnitrap / Exploris 480 system



Appendix 3



The Omnitrap



Appendix 3



RF₂

Q2 segment

nent - slow beating Cll

- slow heating CID
- resolving DC isolation
- sweep isolation
- broadband or tailored excitation

Q5 segment

- electron ionization dissociation (EID)
- electron capture dissociation (ECD)
- hydrogen ion activated dissociation (HIAD)
- slow heating CID
- resolving DC isolation
- sweep isolation
- broadband or tailored excitation
- Q7 segment
 - UV photo-dissociation,

Q8 segment

- ion accumulation
- UV photo-dissociation

Gas lines installation

Gas Lines Connections:

1/8' stainless steel tubing

- 1. H_2 gas outlet (purge line) \rightarrow ion source purge valve
- 2. N_2 gas outlet (purge line) \rightarrow omnitrap purge valve
- 3. N_2 gas outlet to IMS drift cell
 - \rightarrow IMS needle valve
- 4. N_2 gas inlet (tank line)
 - \rightarrow omnitrap tank valve
- 5. H_2 gas inlet (tank line)
 - \rightarrow ion source tank valve

Gas & Regulator specs:

- Ultra-high purity gas supply (UHP > 99.999% pure) at 600 ±50 kPa [6.0 ±0.5 bar]
- Two-stage regulator connected to the gas tank is preferred – stainless steel tubing with double-ferrule compression fittings (1/8" or 1/4" fittings) must be used exclusively.

Backpressure settings:

- P(N₂) = 3 bar
- P(H₂) = 5 bar



Appendix 3

Omnitrap Software science and technology

Omnitrap Software: Standard Mode

аѕтассн science and technolog



M



Omnitrap Software

Appendix 3

asmatech



Omnitrap Software: Neutral Mode

Appendix 3 _ • ×

🗼 MainWindow					
	Time: 88 ms State : Idle Loop Cour	nt : 0	Sequence File:		Mode : Omnitrap Apply 🔹
	Bundles 🗧 🧮 🛍 🕅 🗸	4	Instructions	🔲 - 🗀 🔞 💰 🔶 - 🗔	Omnitrap / IMS DC states Mode : Neutral Y
	Initialization	[↑] 1	External Loop Start	Reps 65536 0	Normal Q2 Bundle Library C
Electron Source V	Number of Loops 65536	2	Trigger In	Channel Ch2 · Ø	Process Transfer
	RF Freq (kHz) 1300	3	RF Amplitude	Ampl[V] 250 0	Process
Ion Source ~	Min m/z 127.52	4	RF Frequency	RF[KHz] 1300 🛛 🕹 1	Broadband
Ion Mobility Drift Cell	Max 11/2 032.03	5	RF Duty Cycle	d [%] 50 1	L1 Hex1 Hex1 L2 Q1 Q2 Q3 Q4 Q5 Q6 Q7 Q8 q9 L3 Hex2 Excitaion Q2
	Injection 02	6	Delay	T [ms] 3 4	35 5 5 4 2 0 2 4 5 6 8 10 25 35 0 Broadbard
Vacuum ~	Transfer Time (ms) 5	7	DC State	Desc Normal Q2 🛛 🕹 4	Inject Q2 Excitation Q5
PE Concretor	Trapping Time (ms) 10	8	Delay	T [ms] 5 9	
RF Generator		9	Gas Pulse 1	T [us] 225 9	CID Q2
Diagnostics ~		10	Delav	T [ms] 2 11	··
	ResDC Isolation Q2	11	DC State	Desc Inject 02 V 11	L1 Hex1 Hex1 L2 Q1 Q2 Q3 Q4 Q5 Q6 Q7 Q8 q9 L3 Hex2 CID Q5
	Delay from Gas (ms) 1	12	Delay	T [ms] 5 16	6 5 5 4 2 0 2 4 5 6 8 10 25 35 0
	RF Freq (KHz) 440.944	13	DC State	Desc Confine O2 × 16	Confine 02 ExD
	Resolving DC (V) 53	14	Delay	T [ms] 10 26	
	Isolation Mass (m/z) 1422	15	Dolay	T [me] 1 27	Process DC States
	RF Freq Return (kHz) 1309.77	15			
		10	RF Frequency	RF[RH2] 440.944	Hex1 Hex1 La c1 c2 c1 c1 c5 c5 c7 c2 c2 c2 La La La
	CID Q2	11	Delay		A B L2 Q1 Q2 Q3 Q4 Q5 Q6 Q7 Q8 Q9 L3 Mex2
	RF Freq (kHz) 842.568	18	Resolving DC Q2	Q2 Res 53	
	Mode CIDtheoretical ~	19	Delay	T [ms] 6 35	Resolving DC Q2 Delay
	Amplitude (mV) 1	20	DC State	Desc Confine Q2	Gas Pulse 1
	Duration (ms) 10	21	Delay	T [ms] 5 40	
	q value 0.2	22	RF Frequency	RF[KHz] 1309.77 🛛 🕹 41	Hav1 Hav1
		23	Delay	T [ms] 1 42	L1 A B L2 Q1 Res Q3 Q4 Q5 Q6 Q7 Q8 q9 L3 Hex2 Gas Pulse 3
	Ejection Q2	24	Gas Pulse 2	T [µs] 230 42	35 5 5 10 2 53 2 4 5 6 8 10 25 35 0 6 RF Amplitude
	Ejection Lens (V) 6	25	Delay	T [ms] 1 43	Confine Q2
	Transfer Time (ms) 10	26	RF Frequency	RF[KHz] 842.568 🛛 🕹 44	RF Frequency
- USB Connection: UK					

Omnitrap Software: Expert Mode

MainWindow

Fasmatech

Appendix 3 – 🔹 🗴

Mh



Omnitrap Software: Bundle & Instruction Libraries





BUNDLES: STANDARD mode



List of Instructions



Instruction	Parameters	Values	Description	Appendix 3
Trigger In	Channel	1, 2, 1+2	Set at 2	
	Edge	positive, negative	Set at negative	
	Туре	Normal, MS2	Set at MS2	
RF Frequency	Frequency	150kHz 2500kHz	Set depending on the desired mass range.	
	Mode	Manual, CIDTheoretical/Calibration, ResDCtheoretical/Calibration, SweepTheoretical/Calibration		
	State	ON/OFF		
	m/z			
	q value	0.01 – 0.7		
	Min m/z , Max m/z	calculated		
RF Amplitude	Voltage amplitude	0V 400V	Always set at 250 V.	
RF Duty Cycle	% duty cycle	0 100 %	Always set at 50%.	
Delay	Time	ms		
Gas Pulse 1 (N ₂)	Time	μs	Set at 215 to 220 µs	
Gas Pulse 2 (N ₂)	Time	μs	Set at 220 to 225 µs	
Gas Pulse 3 (H ₂)	Time	ha		
UV Shutter	Time	ms	unavailable	

List of Instructions



Instruction	Parameters	Values	Description	Appendix 3
Dipolar Excitation	Quad segment	Q2, Q5		
	Secular frequency (ω_{exc})	1 … 300 kHz		
	Amplitude	0 5000 mV		
	Duration T	ms	Use 10 ms or 20 ms	
	q value	0.01 – 0.7	Use 0.1 , 0.15 or 0.5 depending on desired mass range	
	m/z			
	RF frequency	calculated		
El Source	State	ON/OFF		
Ion Source	State	ON/OFF	unavailable	
Sweep Isolation	Edit Waveform			
	Quad.	Q2, Q5		
	Gain	0 5000 mV		
	m/z			
	Q value			
DC States	Lenses Voltages	-150150 V		
	Q1-Q9 Voltages	-150150 V		
	Hexapole Voltage	-150150 V		
Trigger Out	Time	μs	Signal connected to the IMS picoscope	

Omnitrap Bundles

Indicative list of bundles:

"Injection ..." bundle, and finish with an

"Ejection to ..." bundle.



Appendix 3

TRANS	TRANSFER		SS
External Transfer	Internal Transfer	Ion Activation	Ion Isolation
Injection Q2	Transfer Q2 to Q5	Initialization	ResDC Isolation Q2
Injection Q5	Transfer Q2 to Q8	CID Q2	ResDC Isolation Q5
Ejection Q2	Transfer Q2 to Q9	CID Q5	Sweep Isolation Q2
Ejection Q5	Transfer Q5 to Q2	Broadband Excitation Q2	Sweep Isolation Q5
	Transfer Q8 to Q2	Broadband Excitation Q5	
	Transfer Q9 to Q2	Tailored Excitation Q2	
		Tailored Excitation Q5	
ote: /ery sequence must start with a hitialization" bundle follows by an		UVPD	

Omnitrap Software: Modules

 \sim

Appendix 3

Power		•
RF Hex Traps	500	500.01 [V]
RF Drift Cell	45	44.90 [V]
IMS In Lift	800	767.40 [V] 0.37 [mA]
IMS Out Lift	800	768.01 [V] 0.33 [mA]
Hex DC	0	-0.02 [V]
L8	-100	-99.37 [V]
Detector		•
Gain	1000	978.75 [V]

science and technology



Electron Sou	irce	^
Filament		•
Current	5	5.07 [A]
Potential	- 53	-52.93 [V]
Set Current	00:00:00	00:00:00
(hh:mm:ss)		Start

Lens Electrode	25	
E1	- 20	-19.86 [V]
E2 Transmit	20	20.19 [V]
E2 Deflect	- 150	-149.94 [V]
E3	350	349.82 [V]
Steering Plate	5	~
S2 Transmit	-5	[V]
S2 Deflect	-150	[V]

Electrometer

0.00	[uA]
2µА	*
Disabled	*
	0.00 2µA Disabled

-	800	104.01 [1] 1 000000
Exit Lens	1200	1204.40 [V] Negative
Focusing Lens	500	497.68 [V] Positive
Steering		
Top Left	0	0.66 [\
Top Right	-50	-50.18 [V
Bottom Left	40	42.56 [V
Bottom Right	0	0.81 [\
S1 Transmit	15	[\
S1 Deflect	-150	[\
RF Generato	or	/
RF Generato	or	1
RF Generato PSUs Positive	241.76	[V] 0.09 [A]
RF Generato PSUs Positive Negative	241.76 241.47	A] 0.0 [V]
RF Generato PSUs Positive Negative Current Limit	241.76 241.47 1.5	A] 0.09 [V] A] 0.00 [V] A]

Ion Source

Power

Vacuum ~ : Pressure Omnitrap WRG_S: +2.3e-5 [mbar] Omnitrap Back Line / APG100_XM +3.5e-3 Purge Ion Mobility Spectrometer ~ Segmented RF Hex WRG_S +2.6e-6 [mbar]

APG100_XM : +1e-3

IMS Hex / Detector WRG_S +3e-7

Purge	Full	Omnitrap Gas Line	12
Dura		1. to . 120	Įs
Purge	Full	Ion Source Gas Line	
Purge	Full	1 to 120 Ion Mobility Gas Line	5
mnitrap Gas Tank		•	
on Source Gas Tank		•	
on Mobility Gas Tank	6		

Omnitrap Purge Ion Source Purge Ion Mobility Purge Back Valve 0

Vacuum Monitor

Vent Valve

Drift Cell

FSM	Enabled
FSM State	RUNNING_STATE

Speed		Temperature		Power		State
1499	[rps]	39.00	[C]	12	[W]	
1499	[rps]	40.00	[C]	12	[W]	
1000	[nps]	35.00	[C]	13	[W]	
998	[rps]	39.00	[0]	33	[W]	
1499	[rps]	38.00	[0]	12	[W]	
1500	[rps]	38.00	[C]	11	[W]	
	Sp 1499 1499 1000 998 1499 1500	Speed 1499 [rps] 1499 [rps] 1000 [rps] 998 [rps] 1499 [rps] 1500 [rps]	Speed Tempe 1499 [грв] 39.00 1499 [грв] 40.00 1000 [грв] 35.00 998 [грв] 39.00 1499 [грв] 39.00 1500 [грв] 38.00	Speed Temperature 1499 [грв] 39,00 [C] 1499 [грв] 40,00 [C] 1000 [грв] 35,00 [C] 998 [грв] 39,00 [C] 1499 [грв] 38,00 [C] 1500 [грв] 38,00 [C]	Speed Temperature F 1499 [TPS] 39,00 [C] 12 1499 [TPS] 40,00 [C] 12 1000 [TPS] 39,00 [C] 13 998 [TPS] 39,00 [C] 33 1499 [TPS] 38,00 [C] 12 1500 [TPS] 38,00 [C] 11	Speed Temperature Power 1499 [грв:] 39.00 [C] 12 [W] 1499 [грв:] 40.00 [C] 12 [W] 1000 [грв:] 35.00 [C] 13 [W] 998 [грв:] 39.00 [C] 13 [W] 1499 [грв:] 38.00 [C] 12 [W] 1500 [грв:] 38.00 [C] 11 [W]

Pass X

Conditional Pass

Fail

X Pass

Vacuum

Pressure

Omnitrap

Drift Cell

Purge

WRG_S:+3.1e-5

WRG_S:+8.2e-6

WRG_S:+1.9e-6

APG100_XM:+1.6e-3

Omnitrap Gas Line

Ion Source Gas Line

Ion Mobility Gas Line

Omnitrap Back Line / APG100_XM : +5e-3

Full

Full

Full

Ion Mobility Spectrometer

Segmented RF Hex

IMS Hex / Detector

Purge

Purge

Purge

Omnitrap Gas Tank

Ion Source Gas Tank Ion Mobility Gas Tank

Omnitrap Purge

Ion Source Purge

Ion Mobility Purge

Back Valve

Vent Valve

Conditional Pass

~

:

[mbar]

~

[mbar]



	speed		Temperature			
Turbo 1	1499	[rps]	44.00	[C]	12	
Turbo 2	1499	[rps]	46.00	[C]	11	
Turbo 3	999	[rps]	39.00	[C]	12	1
Turbo 4	998	[rps]	43.00	[C]	34	
Turbo 5	1499	[rps]	42.00	[C]	12	
Turbo 6	1500	[rps]	42.00	[C]	11	

Vacuum Monitor FSM Enabled FSM State RUNNING_STATE ower [W] [W] [W] [W] ([W]

Drift Cell pressure ~ 1e⁻³ mbar (with IMS needle valve closed) **IMS Hex/ Detector** pressure ~1e⁻⁶ mbar (with IMS needle valve closed)

Segmented RF Hex pressure < 1e⁻⁵ mbar (with IMS needle valve closed)

- **Back Line / Purge** pressure < 5e⁻³ mbar
- **Omnitrap pressure should be ~3e⁻⁶ mbar** when Exploris is in StandBy or Run mode (N2 is injected into the HCD cell). Pressure should drop at **2 to 4e⁻⁶ mbar** when Exploris is in Stop mode.

Appendix 3

Vacuum module – Pressure readings

State


Vacuum module: Purge Gas



Appendix 3

Pressure WRG_S: +2.3e-5 Omnitrap Omnitrap Back Line / APG100_XM : +3,4e-3 Purge Ion Mobility Spectrometer [S] 30 \checkmark Purge Full Omnitrap Gas Line [S] 30 Purge Full Ion Source Gas Line Purge Full Ion Mobility Gas Line

Omnitrap Gas Line

- <u>Purge</u>: The omnitrap purge (OP) valve is opened; omnitrap gas tank (OT) valve is closed, and the gas lines of pulse valves 1 and 2 (N₂) are purged.
- <u>Full Purge</u>: Both the omnitrap purge (OP) valve and omnitrap gas tank (OT) valve are opened and the gas lines of pulse valves 1 and 2 (N₂) are purged. The N₂ tank must be closed!

Ion Source Gas Line

- <u>Purge</u>: The ion source purge (ISP) valve is opened; ion source gas tank (IST) valve is closed, and the gas line of pulse valve 3 (H₂) is purged.
- <u>Full Purge</u>: Both the ion source purge (ISP) valve and ion source gas tank (IST) valve are opened, and the gas line of pulse valve 3 (H_2) is purged. The H_2 tank must be closed!
- > Monitor Back Line / Purge pressure and set time (s) accordingly until pressure drops at ~ 10^{-3} mbar.



Pass 🛛



Fail

Vacuum control FSM settings

VacCtrl Low Level1 VacCtrl Low Level2 Vac Ctrl Fsm Vac Ctrl Fsm Config El Box El Box Emeter Chart MSW Box FPGA USB3



Ар	pendix	3 ک
----	--------	-----

System	Purge	Get	Get Addr	System	Purge	Gauge	Gauge	Гуре	Ì	Set Three	hold, Active (Gaug	es		Get Thre	sholds
pump	pump	lype		pump	pump				Stopped Pres	5.00	e-5 mbar	\sim	N2		+5e-5	
		Edward:	1						Hi Vacuum	8.00	e-5 mbar	~	N2		+8e-5	
		Edwards	2			Gauge 1	WRG_S	~]	SpinDown Pres	5.00	e-3 mbar	7	N2		+5e-3	
		Edward:	3						Fore Vacuum	9.90	e-2 mbar	~	N2		+9.9e-2	
		Edwards	4						Atmosphere	5.00	e+2 mbar		N2		+5e2	1
		Edward:	5													
		Edward:	6						Stopped Pres	5.00	e-5 mbar	~	N2		+5e-5	
T	Load fr	om Readbar	rks	Set Pump (Settings				Hi Vacuum	1.00	e-4 mbar	~	N2		+1e-4	
L.	Lodd II			oor ramp (ootango	Gauge 2	WRG_S	~	SpinDown Pres	5.00	e-3 mbar	~	N2		+5e-3	
	Loi	ad Defaults	1	Get Pump :	Settings				Fore Vacuum	5.00	e-1 mbar	~	N2		+5e-1	
						41C			Atmosphere	2.00	e+2 mbar	\sim	N2		+2e2	\leq
Set Value	e in ms		Get Va	lue					Stopped Pres	5.00	e-5 mbar	~	N2		+5e-5	
27000		27000							Hi Vacuum	8.00	e-5 mbar	~	N2		+8e-5	
500		500				Gauge 3	WRG_S	~	SpinDown Pres	5.00	e-3 mbar	~	N2		+5e-3	
2000		2000					-		Fore Vacuum	9.90	e-2 mbar	~	N2		+9.9e-2	
5000		5000						3	Atmosphere	5.00	e+2 mbar	1	N2		+5e2	
179200		179200				-	6	-			1				1	
5400000		5400000							Stopped Pres	5.00	e-5 mbar	~	N2		+5e-5	
1800000	0	1800000							Hi Vacuum	8.00	e-5 mbar	~	N2		+8e-5	
60000		60000				Gauge 4	WRG_S	~	SpinDown Pres	5.00	e-3 mbar	~	N2		+5e-3	
500		500							Fore Vacuum	9.90	e-2 mbar	~	N2		+9.9e-2	
500		500						5	Atmosphere	5.00	e+2 mbar	~	N2		+5e2	
5000		5000							Stopped Pres	5.00	e-5 mbar	~	N2		+5e-5	
10000	1	10000							Hi Vacuum	8.00	e-5 mbar	7	N2		+8e-5	
6990		6990				Gauge 5	WRG_S	~	SpinDown Pres	5.00	e-3 mbar		N2		+5e-3	
4995		4995							Fore Vacuum	9.90	e-2 mbar	1	N2		+9.9e-2	
Loa	ad From F	Readbacks	Set Ti	ming Paran	meters				Atmosphere	1.80	e-6 mbar	~	N2		+1.8e-6	
	Load De	efaults	Get Ti	iming Parar	meters							Loa	ad From F	Readbacks	Set Three	sholds
													Load D	efaults	Get Three	eholde
	□ □ □ □	Image: Set Value in ms 2 2 3 1 </td <td>Image: Set Value in ms 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 500 500 500 2 2000 2 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 6 1800000 6 500 6 500 5 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 6990 6</td> <td>Image: Set Value in ms Get Value in ms 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500</td> <td>Image: Set Value in ms Get Value 2 2000 2 2 <</td> <td>Image: Set Value in ms Get Value Set Value in ms Set Value</td> <td>Image: Set Value in ms Get Value Gauge 1 179200 179200 179200 Set Value in ms Get Value Gauge 3 Gauge 4 6 5000 5000 6 10000 60000 6 10000 5000 6 5000 500 6 5000 500 6 10000 10000 6 10000 10000 6 10000 60990 6 10000 10000 6 10000 10000 6 10000 10000 6 4995<</td> <td>Image: Set Value in ms Get Value Gauge 2 WRG_S Gauge 3 WRG_S Gauge 4 WRG_S Set Value in ms Get Value Gauge 4 WRG_S Gauge 5 WRG_S Gauge 6 Solo Solo Solo Gauge 5 WRG_S Gauge 5<!--</td--><td>Image: Set Value in ms Get Value Gauge 3 WRG_S Set Value in ms Get Value Gauge 4 WRG_S Set Value in ms Get Value Gauge 5 WRG_S Set Value in ms Get Value Gauge 500 Gauge 500 Gauge 50 <t< td=""><td>Image: Set Value in ms Get Value Source Set Value in ms Get Value Source Source Stopped Pres Set Value in ms Get Value Gauge 1 WRG_S ~ Source Stopped Pres Hi Vacuum Source Gauge 2 WRG_S ~ Set Value in ms Get Value Gauge 3 WRG_S ~ Source Source Stopped Pres Source Gauge 3 WRG_S ~ Source Gauge 3 WRG_S ~ Source Stopped Pres Hi Vacuum Source Stopped Pres Hi Vacuum Source Source Stopped Pres Source Gauge 3 WRG_S ~ Stopped Pres Hi Vacuum Source Stopped Pres Hi Vacuum Source Source Source Stopped Pres 179200 179200 Gauge 4 WRG_S ~ Stopped Pres 1800000 1800000 Gauge 5 WRG_S ~ Stopped Pres Source Source Source Stopped Pres Hi Vacuum Source</td><td>Image: Stopped Press 5.00 Image: Stopped Press 5.00</td><td>Image: Set Value in ms Get Value Set Value in ms Get Value</td><td>Image: Stopped Press 5.00 e5.00 e7.00 Fore Vacuum 8.90 e2.00 e7.00 e</td><td>Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e3mbar N2 Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e5mbar</td><td>Image: State of the state</td><td>Stopped Pres 500 65 mbar N2 665 I Edward I 665 650 I Edward I 665 650 650 I Edward I 1 667 650 I Edward I 1 667 650 650 I Edward I 1 1 667 164 I Edward I 1 1 164 164 I I Edward Edward 10 100 100 164 I I I I I I 100 1000 1000 1000 1000 1000 1000 1000 1000 10</td></t<></td></td>	Image: Set Value in ms 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 500 500 500 2 2000 2 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 6 1800000 6 500 6 500 5 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 6990 6	Image: Set Value in ms Get Value in ms 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 2000 2 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 5 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500 6 500	Image: Set Value in ms Get Value 2 2000 2 2 <	Image: Set Value in ms Get Value Set Value in ms Set Value	Image: Set Value in ms Get Value Gauge 1 179200 179200 179200 Set Value in ms Get Value Gauge 3 Gauge 4 6 5000 5000 6 10000 60000 6 10000 5000 6 5000 500 6 5000 500 6 10000 10000 6 10000 10000 6 10000 60990 6 10000 10000 6 10000 10000 6 10000 10000 6 4995<	Image: Set Value in ms Get Value Gauge 2 WRG_S Gauge 3 WRG_S Gauge 4 WRG_S Set Value in ms Get Value Gauge 4 WRG_S Gauge 5 WRG_S Gauge 6 Solo Solo Solo Gauge 5 WRG_S Gauge 5 </td <td>Image: Set Value in ms Get Value Gauge 3 WRG_S Set Value in ms Get Value Gauge 4 WRG_S Set Value in ms Get Value Gauge 5 WRG_S Set Value in ms Get Value Gauge 500 Gauge 500 Gauge 50 <t< td=""><td>Image: Set Value in ms Get Value Source Set Value in ms Get Value Source Source Stopped Pres Set Value in ms Get Value Gauge 1 WRG_S ~ Source Stopped Pres Hi Vacuum Source Gauge 2 WRG_S ~ Set Value in ms Get Value Gauge 3 WRG_S ~ Source Source Stopped Pres Source Gauge 3 WRG_S ~ Source Gauge 3 WRG_S ~ Source Stopped Pres Hi Vacuum Source Stopped Pres Hi Vacuum Source Source Stopped Pres Source Gauge 3 WRG_S ~ Stopped Pres Hi Vacuum Source Stopped Pres Hi Vacuum Source Source Source Stopped Pres 179200 179200 Gauge 4 WRG_S ~ Stopped Pres 1800000 1800000 Gauge 5 WRG_S ~ Stopped Pres Source Source Source Stopped Pres Hi Vacuum Source</td><td>Image: Stopped Press 5.00 Image: Stopped Press 5.00</td><td>Image: Set Value in ms Get Value Set Value in ms Get Value</td><td>Image: Stopped Press 5.00 e5.00 e7.00 Fore Vacuum 8.90 e2.00 e7.00 e</td><td>Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e3mbar N2 Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e5mbar</td><td>Image: State of the state</td><td>Stopped Pres 500 65 mbar N2 665 I Edward I 665 650 I Edward I 665 650 650 I Edward I 1 667 650 I Edward I 1 667 650 650 I Edward I 1 1 667 164 I Edward I 1 1 164 164 I I Edward Edward 10 100 100 164 I I I I I I 100 1000 1000 1000 1000 1000 1000 1000 1000 10</td></t<></td>	Image: Set Value in ms Get Value Gauge 3 WRG_S Set Value in ms Get Value Gauge 4 WRG_S Set Value in ms Get Value Gauge 5 WRG_S Set Value in ms Get Value Gauge 500 Gauge 500 Gauge 50 <t< td=""><td>Image: Set Value in ms Get Value Source Set Value in ms Get Value Source Source Stopped Pres Set Value in ms Get Value Gauge 1 WRG_S ~ Source Stopped Pres Hi Vacuum Source Gauge 2 WRG_S ~ Set Value in ms Get Value Gauge 3 WRG_S ~ Source Source Stopped Pres Source Gauge 3 WRG_S ~ Source Gauge 3 WRG_S ~ Source Stopped Pres Hi Vacuum Source Stopped Pres Hi Vacuum Source Source Stopped Pres Source Gauge 3 WRG_S ~ Stopped Pres Hi Vacuum Source Stopped Pres Hi Vacuum Source Source Source Stopped Pres 179200 179200 Gauge 4 WRG_S ~ Stopped Pres 1800000 1800000 Gauge 5 WRG_S ~ Stopped Pres Source Source Source Stopped Pres Hi Vacuum Source</td><td>Image: Stopped Press 5.00 Image: Stopped Press 5.00</td><td>Image: Set Value in ms Get Value Set Value in ms Get Value</td><td>Image: Stopped Press 5.00 e5.00 e7.00 Fore Vacuum 8.90 e2.00 e7.00 e</td><td>Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e3mbar N2 Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e5mbar</td><td>Image: State of the state</td><td>Stopped Pres 500 65 mbar N2 665 I Edward I 665 650 I Edward I 665 650 650 I Edward I 1 667 650 I Edward I 1 667 650 650 I Edward I 1 1 667 164 I Edward I 1 1 164 164 I I Edward Edward 10 100 100 164 I I I I I I 100 1000 1000 1000 1000 1000 1000 1000 1000 10</td></t<>	Image: Set Value in ms Get Value Source Set Value in ms Get Value Source Source Stopped Pres Set Value in ms Get Value Gauge 1 WRG_S ~ Source Stopped Pres Hi Vacuum Source Gauge 2 WRG_S ~ Set Value in ms Get Value Gauge 3 WRG_S ~ Source Source Stopped Pres Source Gauge 3 WRG_S ~ Source Gauge 3 WRG_S ~ Source Stopped Pres Hi Vacuum Source Stopped Pres Hi Vacuum Source Source Stopped Pres Source Gauge 3 WRG_S ~ Stopped Pres Hi Vacuum Source Stopped Pres Hi Vacuum Source Source Source Stopped Pres 179200 179200 Gauge 4 WRG_S ~ Stopped Pres 1800000 1800000 Gauge 5 WRG_S ~ Stopped Pres Source Source Source Stopped Pres Hi Vacuum Source	Image: Stopped Press 5.00 Image: Stopped Press 5.00	Image: Set Value in ms Get Value Set Value in ms Get Value	Image: Stopped Press 5.00 e5.00 e7.00 Fore Vacuum 8.90 e2.00 e7.00 e	Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e3mbar N2 Image: Stopped Press 500 e5mbar N2 Image: Stopped Press 500 e5mbar	Image: State of the state	Stopped Pres 500 65 mbar N2 665 I Edward I 665 650 I Edward I 665 650 650 I Edward I 1 667 650 I Edward I 1 667 650 650 I Edward I 1 1 667 164 I Edward I 1 1 164 164 I I Edward Edward 10 100 100 164 I I I I I I 100 1000 1000 1000 1000 1000 1000 1000 1000 10

;

Electron Source module

Appendix 3 ______





Electron Sou	ırce	^
Filament	filament On/Off	powerswitch
Current	0 to 6.3	
Potential	-1000 to 0	-0.55 [V]

Lens Electrodes

E1		-0.44 [\
E2 Transmit	-150 to 150	-0.99 [\
E2 Deflect	-300 to 0	-1.47 [\
E3	0 to 1000	-6.84 [\
Steering Plate	es	~
S2 Transmit		[]

Electrometer

Current	-0.11	[uA]
Scale	2µA	*
Bias	Disabled	*

An electrometer connected to skimmer lens S2 is used to monitor the emission current of the filament.

- Current (A): Ignites the filament and controls operation temperature and emission current. Filament current limit is set at Settings → General tab
- *Filament Potential* (V): Defines the electron energy, along with Q5 DC voltage, where: $E_{electron} = V_{Q5} V_{filament}$
- Lens Electrodes E1, E2, E3 and skimmer lens S2 are used to guide and focus the e⁻ beam into the Q5 segment of the omnitrap.
- Lens electrode E2 and Skimmer S2 can take both transmit and deflect values.
 - *Deflect Values* are applied when *El Source* instruction state is set to OFF and used to deflect electrons in order not to enter the trap region.
 - *Transmit Values* are applied when *EI Source* instruction state is set to ON and allow electron irradiation of the ions in Q5.
- Steering plates: not available in this electron source version.



Electron Source module: Filament Characterization Appendix 3

Filament type: ES-046 Ta disc (from Kimball Physics)

- Turn-on: For the first time or if the filament has been exposed to air for a prolonged period, turn on filament power supply and gradually increase current to 5.5 amps to 5.7 amps while monitoring emission current and vacuum pressure. As the cathode heats up, small increases in vacuum pressure will most likely be noticed, due to out gassing. Maintain vacuum pressure at ~10⁻⁵ torr or better. A filament that remains in vacuum or is exposed to air for a short time may be brought to the desired operating temperature almost instantly. Small changes in electron emission will occur during the first 20-30 minutes of operation, until thermal equilibrium is achieved.
- <u>Turn-off</u>: Heater current may be turned off slowly or instantly. Prior to venting, the filament and surrounding structure should be allowed to cool.
- Lifetime: Filament current should not exceed 6.3A to increase lifetime and avoid filament failure.



https://www.kimballphysics.com/downloadable/download/sample/sample_id/77/



Important note: Always load the electron source ECD or EID settings before ignite the filament for warm up!

RF Generator module

RF Generator	r			^
PSUs				
Positive	241.76	[V]	0.09	[A]
Negative	241.47	[V]	0.09	[A]
Current Limit	1.5			[A]

RF Amplitude (V) (both positive and negative PSUs) is controlled by the "*RF Amplitude*" sequence instruction. Always set value at 250 V.

Appendix 3

- Current Limit (A) : default value set at 1.5A
- Temperature (°C) : The temperature of the RF Generator is continuously monitored and regulated by the water-cooling system.
- If temperature exceeds 42°C, a pop-up message appears to notify the user.
- If temperature exceeds 70°C, omnitrap automatically turns into "Stop" state, and all the electronics are switched off.

LED COLOUR TEMPERATURE INDICATOR

Temperature (°C)	18 - 25	26 – 42	43 – 55	56 - 70	70 +
Water Tank Colour	blue	green	orange	red	blinking red

4	Instr	ument	Analysis Graph -
	Þ C	urrent Scan	
	4 C	ontrol	
		Define Scan	
		▲ Setup	
		HCD External Instrument Mode	
		External Instrument Mode *	On
		External Instrument Mode: MS2 Only *	On
		Offset to External Instrument * (V)	14
		Gradient to External Instrument * (V)	-50
		Transfer Time to External Instrument * (ms)	25
		Offset from External Instrument * (V)	0
	Gradient from External Instrument * (V)		75
		Transfer Time from External Instrument * (ms)	55
		C-Trap Exit Lens Close * (V)	35
		HCD Exit Lens Mode	Trigger
		HCD Exit Lens to External Instrument * (V)	50
		HCD Exit Lens from External Instrument * (V)	50
		Trigger Voltage High * (V)	5
		Trigger Voltage Low * (V)	0
		AGC mode *	prescan
		External Handshake	
	S	ystem	
	Þ P	erformance	Affected: System
	⇒ E	ectronics	

Tune: External Instrument Mode (1/2)

External Instrument Mode : This Mode is used for transferring ions out of the back of the HCD-cell to the Omnitrap, which is connected instead of the electrometer. Turning this feature "On" sends ions to the HCD-cell even during full scans with 3eV. In MS2 scans, the NCE or Direct eV setting defines the injection energy into the HCD-cell.

External Instrument Mode: MS2 Only: When External Instrume Mode: MS2 Only is "On", then this feature only applies to MS2 scans.

Offset to External Instrument (V) : Sets the voltage of the front the HCD-cell DC gradient when ions are transported to the Omnitrap.

Gradient to External Instrument (V): Determines the gradient applied across the HCD-cell. This number, when added to the value of "Offset to External Instrument * (V)", is the voltage applied to the back of the HCD-cell DC gradient when ions are transported to the Omnitrap.

Transfer Time to External Instrument (V): The time that the HCD-cell voltages are held to transport ions from the HCD-cell to the Omnitrap.

Offset from External Instrument (V) : Sets the voltage of the front the HCD-cell DC gradient when ions are returned to the HCD-cell from the Omnitrap.

Gradient from External Instrument (V): Determines the gradient applied across the HCD-cell. This number, when added to the value of "Offset from External Instrument * (V)", is the voltage applied to the back of the HCD-cell DC gradient when ions are returned to the HCD-cell from the Omnitrap.

Transfer Time from External Instrument (V) : The time that the HCD-cell voltages are held when ions are transported to the HCD-cell from the Omnitrap.

Omnitrap / Orbitrap Synchronization Rule:

IC Source

Transfer Time to Ext. Instrument ≥ Omnitrap Injection Q2 Time

Transfer Time to Ext. Instrument + Transfer Time from Ext. Instrument ≥ Omnitrap Total Sequence Time





4	Instrument	Analysis Graph -
	Current Scan	
	A Control	
	▲ Define Scan	
	▲ Setup	
	HCD External Instrument Mode	
	External Instrument Mode *	On
	External Instrument Mode: MS2 Only *	On
	Offset to External Instrument * (V)	14
	Gradient to External Instrument * (V)	-50
	Transfer Time to External Instrument * (ms)	25
	Offset from External Instrument * (V)	0
	Gradient from External Instrument * (V)	75
	Transfer Time from External Instrument * (ms)	55
	C-Trap Exit Lens Close * (V)	35
	HCD Exit Lens Mode	Trigger
	HCD Exit Lens to External Instrument * (V)	50
	HCD Exit Lens from External Instrument * (V)	50
	Trigger Voltage High * (V)	5
	Trigger Voltage Low * (V)	0
	AGC mode *	prescan
	External Handshake	
	System	
	Performance	Affected: System
	Electronics	
	IC Source	

C-Trap Exit Lens Close (V): Sets the voltage of the C-Trap Exit Lens during the transport of ions to and from the Omnitrap.

HCD Exit Lens Mode: Determines how the HCD Exit Lens behaves during HCD External Instrument Mode operation. In "Lens" mode, the "HCD Exit Lens to External Instrument * (V)" and "HCD Exit Lens from External Instrument * (V)" control the voltage. In "Trigger" mode, the "Trigger Voltage Low * (V)" and "Trigger Voltage High * (V)" control the voltage and create a 5 ms pulse when transfer to the Omnitrap starts.

HCD Exit Lens to External Instrument (V): The HCD Exit Lens voltage applied when ions are transported to the Omnitrap. For this value to be utilized, the "HCD Exit Lens Mode" must be set to "Lens".

HCD Exit Lens From External Instrument (V): The HCD Exit Lens voltage applied when ions are transported to the HCD-cell from the Omnitrap. For this value to be utilized, the "HCD Exit Lens Mode" must be set to "Lens".

Trigger Voltace High (V): Sets the voltage of the HCD Exit Lens for the first 5 ms of the "Transfer Time to External Instrument * (ms)". After 5 ms, the voltage is switched back to the value defined by "Trigger Voltage Low * (V)". For this value to be utilized, the "HCD Exit Lens Mode" must be set to "Trigger".

Trigger Voltace Low (V): Sets the voltage of the HCD Exit Lens after the first 5 ms of ions being transported to the Omnitrap. For this value to be utilized, the "HCD Exit Lens Mode" must be set to "Trigger".

Off-line method for MS2 experiments (Large Molecules):

- 1. Spray analyte.
- 2. Determine optimal injection time in Full MS mode with AGC Mode: "Prescan".
- 3. Switch to MS2 mode and AGC Mode: "Fixed"; set injection time to the optimal determined in step 2.

For small molecules, you can run in prescan mode for either Full MS or MS2.

Appendix 3

Omnitrap Diagnostics - Trapping tests Q2/Q5/Q8/Q9 - Trapping Time tests Q2/Q5/Q8/Q9

Diagnostics modure: Trapping Tests

- Trapping tests are performed on segments Q2, Q5, Q8 and Q9 of the omnitrap in order to ensure that all injected ions are successfully transfer and trapped at all omnitrap segments.
- Additionally, trapping time tests are performed to check the trapping efficiency on different omnitrap segment during time.



The sequence files that are assigned for every diagnostic test can be set on the settings menu/Trapping Tests tab.

Appendix 3

Settings ×				
General Calibration Files Trapping Tests Waveforms				
Trapping Tests				
Q2 - Trapping Test Sequence: Q2 Trapping Test Auto.ins				
Q5 - Trapping Test Sequence: Q5 Trapping Test Auta.ins				
Q8 - Trapping Test Sequence: Q8 Trapping Test Auto.ins				
Q9 - Trapping Test Sequence: Q9 Trapping Test Auto.ins				
Trapping Time Tests				
Q2 - Trapping Time Test Sequence: Q2 Trapping Time Test Auta.ins				
Q5 - Trapping Time Test Sequence: Q5 Trapping Time Test Auto.ins				
Q8 - Trapping Time Test Sequence: Q8 Trapping Time Test Auto.ins				
Q9 - Trapping Time Test Sequence: Q9 Trapping Time Test Auto.ins				
Set As Default				





Q2 Trapping Test

- Ion trapping in segment Q2 is diagnosed by transferring and trapping ions to Q2, followed by a resolving DC signal applied to successfully isolate a single ion mass distribution, e.g., m/z=1422.
- Pass Criterion: The following conditions should be fulfilled:

 $\frac{TIC_m^*}{TIC_m} > 0.9 \quad \& \quad \frac{(TIC_1^* + TIC_2^*)}{(TIC_1 + TIC_2)} < 0.01$

2) Resolving DC voltage (Q2)

Values alternate between two sequence states:
 i) full mass range transfer to Q2
 ii) single ion mass isolation to Q2



Appendix 3



Q2 Trapping Test

	Instructions	📁 🕼 🕼 🕇 🤟 💽
	External Loop Start	Reps 5000 0
	Trigger In	Channel Ch2 ~ 😣 0
	RF Amplitude	Ampl[V] 250 0
	RF Frequency	RF[KHz] 1300 🛛 1
	RF Duty Cycle	d [%] 50 1
5	Delay	T [ms] 3 4
	DC State	Desc Normal Q2 🛛 🕹 4
3	Delay	T [ms] 5 9
	Gas Pulse 2	T [µs] 225 9
10	Delay	T [ms] 2 11
1	DC State	Desc Inject Q2 😵 11
12	Delay	T [ms] 10 21
3	DC State	Desc Confine Q2 😒 21
4	Delay	T [ms] 15 36
5	Delay	T [ms] 1 37
6	RF Frequency	RF[KHz] 444.794 📎 38
7	Delay	T [ms] 1 39
8	Resolving DC Q2	Q2 Res 53.5 📎 39
9	Delay	T [ms] 6 45
0	DC State	Desc Confine Q2 💛 45
1	Delay	T [ms] 5 50
22	RF Frequency	RF[KHz] 1300 😣 51
23	Delay	T [ms] 1 52
24	Gas Pulse 1	T [µs] 225 52
25	Delay	T [ms] 2 54
26	DC State	Desc Lift Q2 📎 54
27	Delay	T [ms] 5 59
28	DC State	Desc Eject from (📎 59
29	Delay	T [ms] 10 69
30	RF Frequency	RF[KHz] 175.88 🛛 70
31	Delay	T [ms] 10 80
32	DC State	Desc Normal Q2 😣 80
33	External Loop End	80

Appendix 3

- Sequence file path/name: ...\Diagnostics\Trapping Tests\Q2 Trapping Test Auto.ins
- Variable parameters of resolving DC isolation:
 1) RF frequency
 2) Resolving DC voltage (Q2)
- Values alternate between two sequence states:
 i) full mass range tranfer to Q2
 ii) single ion mass isolation to Q2

Sequence state	RF frequency	Resolving DC
full mass range transfer	f _{initial} (=1300 kHz)	0 V
single ion mass (m/z) isolation	f _{m/z @ q=0.55} *	53.0 V

* e.g., m/z = 1422 \rightarrow f ≈ 444 kHz

Q5 Trapping Test

- Ion trapping in segment Q5 is diagnosed by transferring and trapping ions to Q5, followed by a resolving DC signal applied to successfully isolate a single ion mass distribution, e.g., m/z=1422.
- Pass Criterion: The following conditions should be fulfilled:

$$\frac{TIC_m^*}{TIC_m} > 0.9 \quad \& \quad \frac{(TIC_1^* + TIC_2^*)}{(TIC_1 + TIC_2)} < 0.01$$

TIC: total ion current

- Variable parameters of resolving DC isolation:
 1) RF frequency
 2) Resolving DC voltage (OE)
 - 2) Resolving DC voltage (Q5)
- Values alternate between two sequence states:
 i) full mass range transfer to Q5
 ii) single ion mass isolation to Q5

Conditional Pass



Appendix 3

Pass X

Bundles			1 🗿 🗿 🦰 🔒	1
Initialization Number of Loops 5000 RF Frequency (kHz) 1300 Min m/z 130.75 Max m/z 4576.26	Q5	Q2	Hex	1 2 3 4 5
Injection Q2 Transfer Time (ms) 10 Trapping Time (ms) 20 Q8	Q5	Q2	Hex	6 7 8
Transfer Q2 to Q5 Transfer Time (ms) 10 Trapping Time (ms) 10				20 21 22 23
ResDC Isolation Q5 Variation Delay from Gas (ms) 1 RF Freq (kHz) 443.47 Mode ResDCtheoretical ~ Resolving DC (V) 53.5 Isolation Mass (m/z) 1430 Duration (ms) 6 RF Freq Return (kHz) 1300	able param	neters		24 25 26 34 35 36
Transfer Q5 to Q2 Transfer Time (ms) 5				37
Ejection Q2 Ejection Lens (V) 7 Transfer Time (ms) 10 Q8	Q5	Q2	Hex	39 40 41 42

Q5 Trapping Test



Appendix 3 ______

- Sequence file path/name: ...\Diagnostics\Trapping Tests\Q5 Trapping Test Auto.ins
- Variable parameters of resolving DC isolation:
 1) RF frequency
 2) Resolving DC voltage (Q5)
- Values alternate between two sequence states:
 i) full mass range tranfer to Q5
 ii) single ion mass isolation to Q5

Sequence state	RF frequency	Resolving DC
full mass range transfer	f _{initial} (=1300 kHz)	0 V
single ion mass (m/z) isolation	f _{m/z @ q=0.55} *	52.8 V

* e.g., m/z = 1422 \rightarrow f ≈ 441 kHz

Q8 Trapping Test

- Ion trapping in segment Q8 is diagnosed by transferring ions to Q8 and trapping them using segments Q6, Q7 and Q9. This
 causes total ion signal loss in Orbitrap detector. Releasing ions by "opening" segments Q6 and Q7 results in a full mass range
 spectrum.
- <u>Pass Criterion</u>: The following condition should be fulfilled:

 $\frac{TIC^*}{TIC} < 0.001$

TIC: total ion current

- Variable parameters of resolving DC isolation:
 1) Q6 DC voltage
 2) Q7 DC voltage
- Values alternate between two sequence states:
 i) full mass range transfer to Q8
 ii) full mass range trap to Q8

Conditional Pass

X

Pass



Q8 Trapping Test



8-B B Instructions External Loop Start Reps 2000 Trigger In Ch2 Edae Neg Type Normal **RF** Amplitude 250 Ampl[V] ON/OFF ON **RF** Frequency RF[KHz] 1300 Mode Manual ~ **RF Duty Cycle** d [%] 50 Delay T [ms] 3 35 Hex1 DC State Desc Normal Q2 L1 6 Delay T [ms] 5 Gas Pulse 2 220 T [µs] Delay T [ms] 2 11

.

17	DC State	Desc Transfer Q2 L1 35 Hex1 6	\otimes	31
18	Delay	T [ms] 10		41
19	Gas Pulse 1	T [µs] 225		41
20	Delay	T [ms] 2		43
21	DC State	Desc Lift Q8 L1 35 Hex1 6	\otimes	43
22	Delay	T [ms] 5		48
23	DC State	Desc Transfer Q8 L1 35 Hex1 6	\approx	
		L2 25 Q1 2 Q2 0		
	variable	Q3 2 Q4 3 Q5 4		48
na	rameters	Q6 13 Q7 11 Q8 8		
pu	ameters	q9 11 L3 15 Hex2 0		
24	Delay	T [ms] 10		58
25	DC State	Desc Lift to Eject (L1 4 Hex1 5	\otimes	58
26	Delay	T [ms] 5		63
27	DC State	Desc Eject from Q L1 4 Hex1 5	\otimes	63
28	Delay	T [ms] 20		83
29	RF Frequency	RF[KHz] 173.7 Mode Manual v ON/OFF OFF v	\otimes	84
30	Delay	T [ms] 10		94
31	DC State	Desc Normal Q2 L1 35 Hex1 6	\otimes	94
32	External Loop End			94

Sequence file path/name: ...\Diagnostics\Trapping Tests\Q8 Trapping Test Auto.ins

- Variable parameters of "Transfer Q8 to Q2" DC state:
 1) Q6 DC voltage
 2) Q7 DC voltage
- Values alternate between two sequence states:

i) full mass range transfer to Q8



ii) full mass range trap to Q8



sequence state	Q6	Q7
transfer	5 V	6 V
trap	13V	11 V

Appendix 3

Q9 Trapping Test

- Appendix 3
- Ion trapping in segment Q9 is diagnosed by transferring ions to Q9 and trapping them using segments Q7, Q8 and lens L3. This
 causes total ion signal loss in Orbitrap detector. Releasing ions by "opening" segments Q7 and Q8 results in a full mass range
 spectrum.
- <u>Pass Criterion</u>: The following condition should be fulfilled:

 $\frac{TIC^*}{TIC} < 0.001$

TIC: total ion current

- Variable parameters of resolving DC isolation:
 1) Q7 DC voltage
 2) Q8 DC voltage
- Values alternate between two sequence states:
 i) full mass range transfer to Q8
 ii) full mass range trap to Q8

Conditional Pass

X

Pass



Q9 Trapping Test



	Instructions	🚍 • 🛅 🐻 👘 🔹	1
	External Loop Start	Reps 2000	0
	Trigger In	Channel Ch2 v Edge Neg v Type Normal v	0
	RF Amplitude	Ampi[V] 250	0
E.	RF Frequency	RF[KHz] 1300 Mode Manual v ON/OFF ON v	≥ 1
	RF Duty Cycle	d [%] 50	1
	Delay	T [ms] 3	4
	DC State	Desc Normal Q2 L1 35 Hex1 6	⇒ 4
	Delay	T [ms] 5	9
	Gas Pulse 2	T [µs] 220	9



- Sequence file path/name: ...\Diagnostics\Trapping Tests\Q9 Trapping Test.ins
- Variable parameters of "Transfer Q9 to Q2" DC state:
 1) Q7 DC voltage
 2) Q8 DC voltage
- Values alternate between two sequence states:

i) full mass range transfer to Q9



ii) full mass range trap to Q9



sequence state	Q7	Q8
transfer	6 V	7 V
trap	13V	11 V

Appendix 3

Trapping Time test Q2

- Sequence file path/name:
 ...\Diagnostics\Trapping Time Tests\Q2 Trapping Time Test.ins
 - Variable parameter: Injection Q2 bundle Trapping Time t (ms)
 - Scan values: 5, 10, 25, 50, 100, 250, 500 ms
 - <u>Pass Criterion</u>: *TIC*: total ion current $\frac{TIC_{t=500ms}}{TIC_{t=5ms}} > 0.8$



Instructions	• 📜 🗓 🐧 🕇 🗸 💽
External Loop Start	Reps 5000 0
Trigger In	Channel Ch2 - 🛛 🕹 0
RF Amplitude	Ampl[V] 250 0
RF Frequency	RF[KHz] 1300 🛛 🕹 1
RF Duty Cycle	d [%] 50 1
Delay	T [ms] 3 4
DC State	Desc Normal Q2 🛛 🕹 4
Delay	T [ms] 5 9
Gas Pulse 2	T [µs] 225 9
Delay	T [ms] 2 11
DC State	Desc Inject Q2 🛛 😵 11
Delay	T [ms] 75 86
DC State	Desc Confine Q2 🛛 🕹 86
Delay	T [ms] 5 91
Gas Pulse 1	T [µs] 225 91
Delay	T [ms] 2 93
DC State	Desc Lift Q2 🛛 🕹 93
Delay	T [ms] 5 98
DC State	Desc Eject from Q 🛛 😔 98
Delay	T [ms] 10 108
RF Frequency	RF[KHz] 175.88 🛛 109
Delay	T [ms] 10 119
DC State	Desc Normal Q2 😣 119
External Loop End	119

Appendix 3

lons are injected and trapped to Q2.

A 75 ms delay time is needed before trapping time starts, to ensure gas-free trapping evaluation.



Appendix 3

Benchmark MS2 experiments

- slow heating Collisional Induced Dissociation (CID)
 - Electron Ionization Dissociation (EID)
 - Electron Capture Dissociation (ECD)

Appendix 3

science and technology

Slow heating CID (Q2) : Omnitrap sequence



Appendix 3



- Sequence file path/name: ...\OmniTrap\Sequence Files\Templates\MS2 CID Q2.bdl or .ins
- <u>CID parameters</u>: *q value (RF frequency) excitation (secular) frequency excitation amplitude duration*
- Sample: ubiquitin (H2O:MeOH:AcOH, 49:50:1), C=1µM

Gas Pulse 1	Τ [μs] 225
Delay	T [ms] 1
RF Frequency	RF[KHz] 849.775 Mode CIDtheor • ON/OFF ON • V
Delay	T [ms] 1
Dipolar Excitation	Exc[KHz] 78.055 Ampl[mV] 1800 T [ms] 10 <
	Quad Q2 v m/z 1071 q 0.2
	RF[KHz] 849.775
Delay	T [ms] 10



Slow heating CID (Q5) : Omnitrap sequence



Appendix 3



- Sequence file path/name: ...\OmniTrap\Sequence Files\Templates\MS2 CID Q5.bdl or .ins
 - **CID** parameters: q value (RF frequency) excitation (secular) frequency excitation amplitude duration
- Sample: ubiquitin (H2O:MeOH:AcOH, 49:50:1), C=1µM

Gas Pulse 1	Τ [μs] 225	
Delay	T [ms] 1	
RF Frequency	RF[KHz] 849.775 Mode CIDtheor * ON/OFF ON	* *
Delay	T [ms] 1	
Dipolar Excitation	Exc[KHz] 78.055 Ampl[mV] 1700 T [ms] 100 Quad Q5 v m/z 1071 q 0.2 RF[KHz] 849.775	2
Delay	T [ms] 10	
Transfer Q2 to Q5		
L1 Hex1 L2 Q	1 Q2 Q3 Q4 Q5 Q6 Q7 Q8 q9 L3	Hex2

Slow heating CID (Q2 & Q5) – ubiquitin [M+8H]⁸⁺



Slow heating CID – ubiquitin [M+8H]⁸⁺



Appendix 3

Annotated slow heating CID mass spectrum of ubiquitin 8+ and corresponding sequence map.



Pass Criterion: >50% bonds cleaved



Appendix 3

Electron Ionization Dissociation (EID) science and technology

MS2 EID : omnitrap sequence / electron source settings



Appendix 3



•	Sequence file path/name:
	\OmniTrap\Sequence Files\Templates\MS2 ExD.bdl or .ins

Electron Source settings:	
Current	5.6A
Potential (V _{filament})	-53V
E1	-20V
E2 Transmit	0V
E2 Deflect	<i>-150</i> V
E3	<i>450</i> V
S2 Transmit	5V
S2 Deflect	-150V



Sample: ubiquitin (H2O:MeOH:AcOH, 49:50:1) , C=1µM



Electron Ionization Dissociation (EID) – ubiquitin [M+8H]⁸⁺ Appendix 3



Electron Ionization Dissociation (EID) – ubiquitin [M+8H]⁸⁺ Appendix 3 - Faster and Island



m/z

Electron Ionization Dissociation (EID) – ubiquitin [M+8H]⁸⁺ Appendix

Precursor, ionized and selected fragment ions signal intensity (NL) as a function of electron irradiation time on MS2 EID experiments.





Annotated MS2 EID mass spectrum of ubiquitin [M+8H]⁸⁺ ions and corresponding sequence map.



Appendix 3

Electron Capture Dissociation (ECD)

MS2 ECD : omnitrap sequence / electron source settings



Appendix 3



- Sequence file path/name: ...\OmniTrap\Sequence Files\Templates\MS2 ExD.bdl or .ins
 - **Electron Source settings:** Current 5.7A Potential (V_{filament}) -20V *0*V E1 E2 Transmit 20V E2 Deflect -150V E3 400V S2 Transmit 20V S2 Deflect -150V
- $C_{electron} = V_{Q5} V_{filament}$ $\approx 0eV$
- Sample: ubiquitin (H2O:MeOH:AcOH, 49:50:1) , C=1µM



Electron Capture Dissociation (ECD) – ubiquitin [M+8H]⁸⁺

Appendix A Fasmarecu



Electron Capture Dissociation (ECD) – ubiquitin [M+8H]⁸⁺

Appendix B Fasmarech



Electron Capture Dissociation (ECD) – ubiquitin [M+8H]⁸⁺ Appendix 3 - Fasmared

Precursor, charged reduced and fragment ions signal intensity (NL) as a function of electron irradiation time on MS2 ECD experiments.



Annotated MS2 ECD mass spectrum of ubiquitin [M+8H]⁸⁺ ions and corresponding sequence map.

Pass



Appendix 3

Accumulation Mode science and technology



Accumulation mode in MS3 working flow: Omnitrap Sequence

number of		Instructions	🕂 ↑ 🗴 🐻 🕂 🗸							Appendix 3
accumulation loops	1	External Loop Start	Reps 5000	0						
(multiple injections to	2	Internal Loop Start	Reps 10 ACCUMULATION START	0						
omnitrap)	3	Trigger In	Channel Ch2 v Edge Neg v Type MS2 v	0 31		DC State	Desc Lift Q2 L1 35 Hex1 6	\otimes	95	
	4	RF Amplitude	Ampl[V] 250	0 32	2	Delay	T [ms] 10	1	05	Transfer from 02 to 08
Initialization -	5	RF Frequency	RF[KHz] 1100 Mode Manual · ON/OFF ON ·	1 33	3	Gas Pulse 2	T [µs] 220	1	05	
	6	RF Duty Cycle	d [%] 50	1 34		Delay	T [ms] 2	1	07	Store to Q8 for
	7	Delay	T [ms] 3	4 35	5	DC State	Desc Transfer Q2 L1 35 Hex1 6	≥ 1	07	ion accumulation
ſ	8	DC State	Desc Normal Q2 L1 35 Hex1 5	4 36	5	Delay	T [ms] 10	1	17	
	9	Delay	T [ms] 5	9 37		Internal Loop End	ACCUMULATION END	11	70	
	10	Gas Pulse 2	T [µs] 225	9 38	3	Delay	T [ms] 5	11	75	
Injection to O2	11	Delay	T [ms] 2	11 39		Gas Pulse 1	Τ [μs] 225	11	75	
Injection to Q2 -	12	DC State	Desc Inject Q2 L1 7 Hex1 5	11 40		Delay	T [ms] 1	11	76	
	13	Delay	T [ms] 10	21 41		DC State	Desc Lift Q8 L1 35 Hex1 6	≫ 11	76	T
	14	DC State	Desc Confine Q2 L1 35 Hex1 5	21 42	2	Delay	T [ms] 5	11	81	- Transfer from Q8 to Q2
	15	Delay	T [ms] 10	31 43	3	DC State	Desc Transfer Q8 L1 35 Hex1 6	≫ 11	81	
Ī	16	Gas Pulse 1	T [µs] 225	31 44	1	Delay	T [ms] 10	11	91	
	17	Delay	T [ms] 1	32 45	5	Gas Pulse 2	Τ [μs] 220	11	91	
	18	RF Frequency	RF[KHz] 849.78 Mode Manual · ON/OFF ON · V	33 46	;	Delay	T [ms] 2	11	93	
	19	Delay	T [ms] 1	34 47	7	DC State	Desc Lift Q2 L1 35 Hex1 6	≫ 11	93	
	20	Dipolar Excitation	Exc[KHz] 76.6 Ampl(mV] 1800 T [ms] 10	44 48	3	Delay	T [ms] 5	11	98	
	21	Delay	T [ms] 30	74 49		DC State	Desc Eject from Q L1 4 Hex1 5	≫ 11	98	Eightight from Q2
ſ	22	Delay	T [ms] 1	75 50		Delay	T [ms] 10	12	08	- Ejection from Q2
	23	RF Frequency	RF[KHz] 1100 Mode Manual • ON/OFF ON •	76 51	Ī	RF Frequency	RF[KHz] 175.88 Mode Manual v ON/OFF OFF v	≥ 120	09	
	24	Delay	T [ms] 1	77 52	2	Delay	T [ms] 10	12	19	
	25	Resolving DC Q2	Q2 Res 0 m/z 500 L1 35 🛛	77 53	3	DC State	Desc Normal Q2 L1 35 Hex1 5	≥ 12	19	
MS3 Resolving DC	26	Delay	T [ms] 6	83 54	E	External Loop End		12	19	
Isolation Q2	27	DC State	Desc [Confine Q2] L1 35 Hex1 5 ≫	83						
	28	Delay	T [ms] 10	93						
	29	RF Frequency	RF[KHz] 1100 Mode Manual • ON/OFF ON • 😽	94						52
	30	Delay	T [ms] 1	95						53








Accumulation mode – Full Mass Range





z=2

z=1

atech

Accumulation mode – Single Mass (m/z=524)



TECH

Ion Accumulation Efficiency

TECH



Pass Criterion: Gain >10-fold.



Fail

Ion Mobility Spectrometry experiments science and technology

IMS experiments



Conclusion

 Omnitrap/IMS/Exploris 480 system has successfully passed all acceptance criteria and was commissioned at Karolinska institute project partner